plication No.	Applicant(s)
	CHALMERS ET AL.
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a Q. Pham	2877
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6. ☐ Interview Summary Paper No./Mail Dat 7. ☐ Examiner's Amendr	te
	TS. This application is subject to IMPEP 1308. 9/05. 9/05. 35 U.S.C. § 119(a)-(d) or (f). 9 received. 9 received in Application No 9 ents have been received in this 9 is communication to file a reply 1 of this application. 1. Note the attached EXAMINER 1 eason(s) why the oath or declarate 1 submitted. 2 Patent Drawing Review (PTO- 1 nendment / Comment or in the Comment or in the Comment of the drawing eader according to 37 CFR 1.121(c) 2 Interview Summary 2 Paper No./Mail Da 3 Examiner's Amendi 8 Examiner's Statement 8 Examiner's Statement 8 Examiner's Statement 1 Interview Summary 1 Examiner's Statement 1 Interview Statement 2 Examiner's Statement 3 Examiner's Statement 4 Interview Statement 5 Examiner's Statement 8 Examiner's Statement 1 Interview Statement 1 Interview Statement 2 Examiner's Statement 3 Interview Statement 4 Interview Statement 5 Examiner's Statement 8 Examiner's Statement 8 Interview Statement 8 Examiner's Statement 8 Interview Statement 9 Interview Statement 1 Interview Statement 1 Interview Statement 1 Interview Statement 2 Interview Statement 3 Interview Statement 5 Interview Statement 6 Interview Statement 7 Interview Statement 8 Interview Statement 9 Interview Statement 1 Interview Statement 1 Interview Statement 1 Interview Statement 1 Interview Stateme

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REASONS FOR ALLOWANCE

1. The following is an examiner's statement of reasons for allowance:

There was no prior art found by the examiner that suggested modification or combination with the cited art so as to satisfy the combination of all the limitations in claims 66, 69, 72, 75, 78, 84, 87, and 89.

Muraoka is the closest reference found by examiner, teaches a film thickness measuring section (70) measures the thickness of the wafer before and after the etching during the transfer of the wafer inside the transfer section (60). However, as argued by applicant in the Remarks dated 12/29/05, Muraoka only teaches the wafer is transferred between stations and to hold the wafer **stationary** while measuring measurement is taken and fails to teach a spectral imager configured to detect light reflected from the wafer as the transfer mechanism is transferring the wafer between stations.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Hoa Q. Pham whose telephone number is (571) 272-2426. The examiner can normally be reached on 7:30AM to 6 PM, Monday through Thursday.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Gregory J. Toatley, Jr. can be reached on (571) 272-2800 ext. 77. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

∕Hoa Q. Phām Primary Examiner Art Unit 2877

HP March 16, 2006